

What is claimed is:

1. A method for coating photoresist on a substrate, comprising the steps of:

 forming grooves on the substrate;

 applying photoresist on the substrate; and

 vibrating the substrate.
2. The method for coating photoresist as claimed in claim 1, wherein the grooves are contiguous and parallel to each other.
3. The method for coating photoresist as claimed in claim 1, wherein each of the grooves has a triangular cross section.
4. The method for coating photoresist as claimed in claim 1, wherein the photoresist is sprayed onto the substrate.
5. The method for coating photoresist as claimed in claim 1, wherein the photoresist is coated by one or more slit nozzles.
6. The method for coating photoresist as claimed in claim 1, wherein the substrate is vibrated in horizontal directions.
7. The method for coating photoresist as claimed in claim 1, wherein the substrate is vibrated in vertical directions.
8. A method for coating photoresist on a substrate, comprising the steps of:

 forming recesses on the substrate;

 applying photoresist on the substrate; and

 vibrating the substrate so as to have the photoresist occupies said recesses

evenly.

9. The method for coating photoresist as claimed in claim 8, further comprising a step of shaping a top portion of the photoresist with an flat exterior surface.
10. A method for coating photoresist on a substrate, comprising the steps of:
 - a) forming protrusions on the substrate;
 - b) applying photoresist on the substrate; and
 - c) vibrating the substrate so as to have the photoresist covering the protrusions and portions beside said protrusions evenly.
11. The method for coating photoresist as claimed in claim 10, wherein in step (b), a plurality of nozzles are respectively located right above apexes of the corresponding protrusions for spraying said photoresist.